

Title (en)

POLISHING PADS AND SYSTEMS AND METHODS OF MAKING AND USING THE SAME

Title (de)

POLIERPADS SOWIE SYSTEME UND VERFAHREN ZUR HERSTELLUNG UND VERWENDUNG DAVON

Title (fr)

TAMPONS À POLIR, SYSTÈMES ET PROCÉDÉS DE FABRICATION ET D'UTILISATION DE TELS TAMPONS À POLIR

Publication

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Application

EP 19890633 A 20191122

Priority

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- IB 2019060064 W 20191122

Abstract (en)

[origin: WO2020109947A1] A polishing pad includes a polishing layer having a first major surface and a second major surface opposite the first major surface. The polishing pad further includes a subpad, which is coupled to the polishing layer, and has a first major surface and a second major surface opposite the first major surface. At least 50% of the subpad, based on the total surface area of the first major surface of the subpad, is optically transparent.

IPC 8 full level

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CPC (source: EP KR US)

B24B 37/04 (2013.01 - EP KR US); **B24B 37/22** (2013.01 - EP KR US); **B24B 37/24** (2013.01 - EP KR US)

Citation (search report)

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- [XYI] US 2015325451 A1 20151112 - MRZYGLOD BRIAN [US], et al
- [X] US 2005197050 A1 20050908 - PRASAD ABANESHWAR [US], et al
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- See references of WO 2020109947A1

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